

Attorney Docker 1...

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

TOTAL OFFICE TECHNOLOGY CENTER 28

\*\*\* Unit: 2814

In re Application of:

SUZUKI et al.

Application No.

Filed: July 11, 2000

For:

FIELD EFFECT TRANSISTOR STRUCTURE WITH BENT GATE

## RESPONSE TO OFFICE ACTION

Commissioner for Patents Washington, D.C. 20231

Dear Sir:

In response to the Office Action dated October 4, 2002, please enter the following amendments and consider the following remarks.

## **AMENDMENTS**

IN THE CLAIMS:

Replace the indicated claim with:

18. (Amended) A semiconductor device comprising:

a compound semiconductor substrate having a first surface and a second surface, the compound semiconductor substrate being electrically isotropic in two mutually orthogonal directions;

first, second, and third active regions on the first surface of the substrate, the first and second active regions being separated by a first insulating region and the second and third active regions being separated by a second insulating region;

a first semiconductor element including

first, second, and third channel regions serially connected, adjacent channel regions having width directions essentially perpendicular to each other,

a first source electrode and a first drain electrode, adjacent to the first, second, and third channel regions and opposing each other with the first, second, and third channel regions therebetween, and in ohmic contact with the first, second, and third active regions, and 02/05/2003 GHILLS 000000005 121216 09613749

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